Abstract Submitted for the TSS07 Meeting of The American Physical Society

Muonium in Silicon Germanium Alloys BRENT CARROLL, ROGER LICHTI, Texas Tech University, PHILIP KING, ISIS Facility, Rutherford Appleton Laboratory, GURKAN CELEBI, Istanbul University — We report observations of muonium defect centers in bulk, single crystalline Silicon Germanium alloys. Analysis of both bond-centered and interstitial T-site muonium gives a test for predictions of isolated hydrogen defect levels in $Si_{1-x}Ge_x$ alloys across the full alloy composition range. Temperature dependent amplitudes for neutral Mu_{BC} and Mu_T from high transverse field muon spin rotation (HTF- μ SR) measurements yield ionization energies for these muonium centers. The hyperfine parameter for Mu_{BC} varies linearly with alloy composition, whereas for Mu_T it varies non-linearly, perhaps due to faster motion among germanium T-sites compared to silicon. Our $\text{HTF-}\mu\text{SR}$ analysis of $\text{Si}_{0.16}\text{Ge}_{0.84}$ shows that the diamagnetic muonium species grows around 130 K with an activation energy of 102(1) meV. Similar data for Si_{0.10}Ge_{0.90} give an activation energy of 67(3) meV. Both HTF- μ SR and RF resonance results show two distinct Mu_T signals for $x \geq 0.84$. These states are tentatively assigned to T-sites with all Ge neighbors versus those with a Si neighbor.

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Date submitted: 26 Feb 2007 Electronic form version 1.4